

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Jiutao Li et al.

Application No.: 10/712,106

Confirmation No.: 8216

Filed: November 14, 2003

Art Unit: 1753

For: SILVER SELENIDE SPUTTERED FILMS
AND METHOD AND APPARATUS FOR
CONTROLLING DEFECT FORMATION IN
SILVER SELENIDE SPUTTERED FILMS

Examiner: R. G. McDonald

OK TO ENTER: /RM/

07/08/2008

AMENDMENT AFTER FINAL ACTION UNDER 37 C.F.R. 1.116

MS AF
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

INTRODUCTORY COMMENTS

In response to the Office Action dated March 28, 2008, finally rejecting claims 1-84, please amend the above-identified U.S. patent application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks begin on page 15 of this paper.